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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Applicant:

Wang Yueh et al.

§ Art Unit: 1752

Serial No.: 10/762,031

§ Examiner: John S.Y. Chu

Filed: January 21, 2004

§ Docket: ITL.1074US  
P18216

For: One Component  
EUV Photoresist

§ Assignee: Intel Corporation

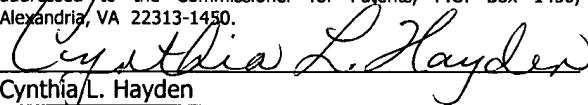
§

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**REPLY TO PAPER NO. 20050307**

Sir:

In response to the office action mailed March 16, 2005, please amend the above-referenced patent application as follows:

Date of Deposit: <u>May 18, 2005</u>
I hereby certify under 37 CFR 1.8(a) that this correspondence is being deposited with the United States Postal Service as <b>first class mail</b> with sufficient postage on the date indicated above and is addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

Cynthia L. Hayden